



Microscopes for Flat Panel Display and Large Scale Integration Inspection

ECLIPSE L300N/L300ND L200N/L200ND

Microscopes for Flat Panel Display
and Large Scale Integration Inspection





L300N

For ø300 mm wafer/
Episcopic optical contrast



L300ND

For 17-inch FPD/
Episcopic and Diascopic optical contrast



L200N

For ø200 mm wafer/
Episcopic optical contrast



L200ND

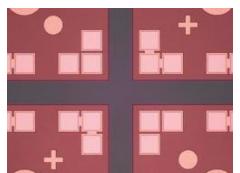
For ø200 mm wafer/
Episcopic and Diascopic optical contrast

Enhanced observation performance and operation

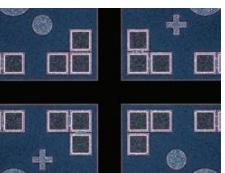
Epi-fluorescence observation widens inspection range—including 365 nm UV excitation

- Highly beneficial when inspecting semiconductor resist residues and organic electroluminescence displays.
- Various observation methods such as brightfield, darkfield, simple polarizing, and DIC are possible on all models.
- With the L300ND/L200ND, diascopic illumination capability adds the illumination through transparent substrates.

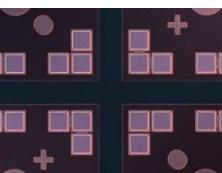
*L300N/L300ND/L200ND only



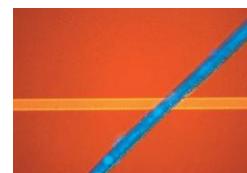
Brightfield observation
of wafer pattern



Darkfield observation



DIC observation



Epi-fluorescence observation
of organic substance on wafer

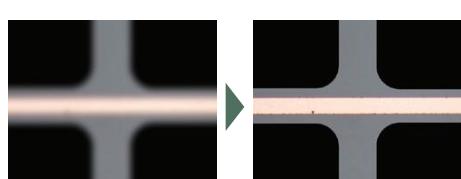
Front operation with easy access

- Minimizes fatigue during lengthy observations, maintaining a safer operator distance from the sample



Target for easier focusing

- Insert a focusing target in the optical path to easily focus on low-contrast samples, such as bare wafers.



Stronger safeguard against contamination

- Antistatic coatings applied to the body, stage, eyepiece tube and other various controls
- Prevents damage to samples and contributes to higher yields

Observation at optimum eyepoint level

- Ultra-wide 25-mm field of view and eyepiece angle adjustment between 0° and 30°
- Operators can adjust eyepoint level to ensure a comfortable viewing position



Fixed-position X-Y fine movement control

- Allows for stage movements and focusing to be carried out with ease



The X-Y fine movement controls are positioned close to the operator.

Illumination

LED

Compact LED illuminators are power saving and achieve long life.



LV-LL LED Lamphouse

Intensilight

- Motorized mercury precentered fiber illuminator for epi-fluorescence observation, with variable light intensity and shutter control, provide excellent flexibility. Lamp centering and focus adjustment are not necessary.

*L300N/L300ND/L200ND only

Filter blocks

For epi-fluorescence observation

- EPI-FL UV-2A
- EPI-FL V-2A
- EPI-FL BV-2A



*L300N/L300ND/L200ND only.
Only one cube is attachable.

Accessories

Nikon's CFI*eo* optical systems are highly evaluated for their unique concept of high NA combined with a long working distance. These lenses have been developed further and evolved achieving the apex in long working distance specifications, correct chromatic aberration, and an optimized lens weight.

Objective lenses

TU Plan Fluor Series	EPI/BD 5x/10x/20x/50x/100x	

Enable brightfield, darkfield, simple polarizing, sensitive polarizing, differential interference, and epi-fluorescence observations with just one lens. Achieves superior chromatic aberration performance with long working distance for all magnifications to adapt to any application.

TU Plan ELWD Series	EPI/BD 20x/50x/100x	

*Brightfield observation (EPI) objective lens enable long working distances while offering higher level chromatic aberration correction than conventional objective lenses. This improves operability for samples with different heights.

TU Plan EPI CR Series	EPI 20x/50x/100x	

*Brightfield observation (EPI) objective lens enable long working distances while offering higher level chromatic aberration correction than conventional objective lenses. This improves operability for samples with different heights.

TU Plan EPI CRB Series	EPI 20x/50x/100x	

*Brightfield observation (EPI) objective lens enable long working distances while offering higher level chromatic aberration correction than conventional objective lenses. This improves operability for samples with different heights.

CFL Plan EPI CR Series	EPI 20x/50x/100x	

Model Magnification NA Working Distance(mm)
TU Plan EPI ELWD (brightfield type) 20x 0.4 19.0
50x 0.6 11.0
100x 0.8 4.5
TU Plan EPI ELWD (brightfield type) 20x 0.4 19.0
50x 0.6 11.0
100x 0.8 4.5

Glass Thickness Correction Range (mm)
0.1-2
0.1-2
0.1-2
0.1-2
0.1-2
0.1-2

Microscope camera

DS-Fi3

This high-resolution camera captures both color and monochromatic images at up to 6,000 x 3,984 pixels. This enables the wide range of images to be captured and them many of them to be stitched together making a single and large combined image.



23.9 megapixel
Color/
Mono/
Chrome
High-
resolution

Digital Sight 1000

Equipped with a 2 megapixel CMOS image sensor, it can capture full HD microscope images. By connecting a microscope to this camera and HDMI monitor, movies and images can be captured and saved onto a pre-inserted SD card in the camera.



5.9 megapixel
Color
High-
resolution

Digital Sight 10

Three main features of the previous models, high-resolution, high sensitivity and low noise, and high-speed live display are offered in 1 camera.



2.0 megapixel
Full HD
Color

Frame Rate	30 fps (1920x1080)	
Max Recordable Pixels	1920x1080	2880x2048

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* See the "Digital Camera Digital Sight Series for Microscopes" catalog for details on Digital Sight features.

Wafer loader NWL200

Combined with the NWL200 wafer loader, the ECLIPSE L200N meets requirements for wafer inspections.

Support for ultra-thin 100 µm wafers

- NWL200 series provides levels of safety and reliability that meet all requirements for inspection of the latest wafers.

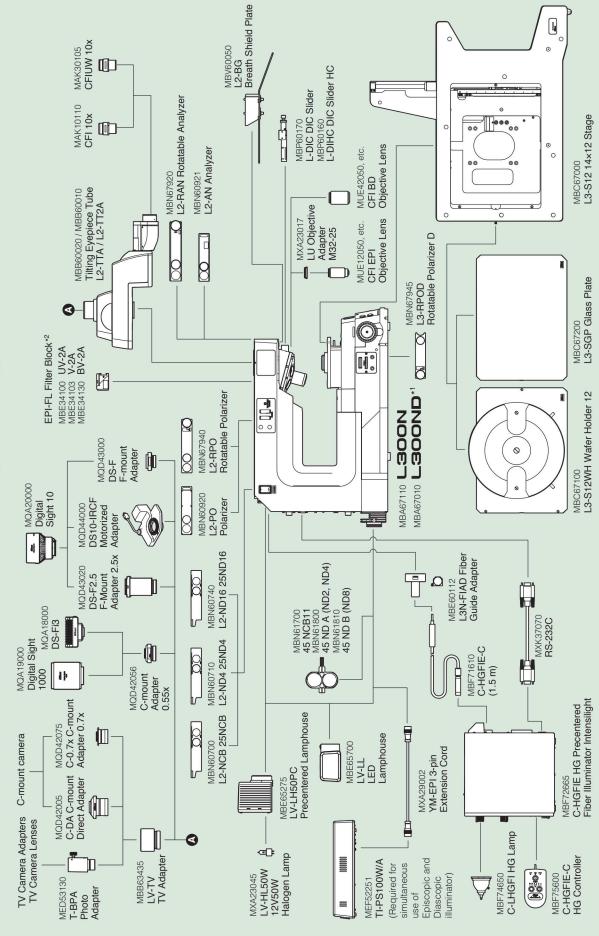
Improved operability and high throughput

- Setting conditions, such as sampling and inspection patterns, and checking the operating status and content of errors can easily be done with the large LCD panel
- Comprehensive file management functions for carriers and samples are useful for automating inspections
- Exceptionally fast elevator, and the loading and unloading of wafers with complete precision by the multi-arm system all contribute to an efficient wafer transfer and exchange

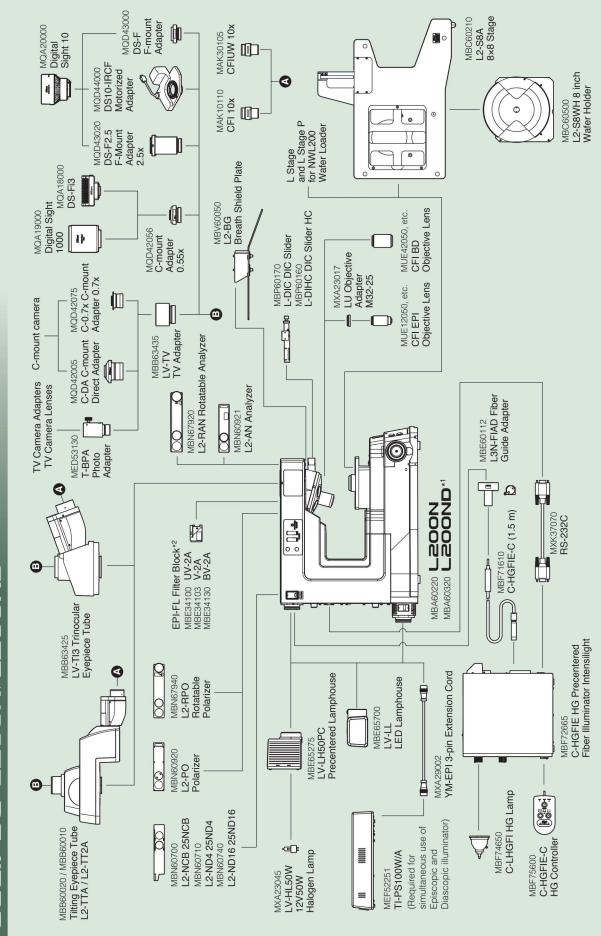


System diagram

ECLIPSE L300N/L300ND

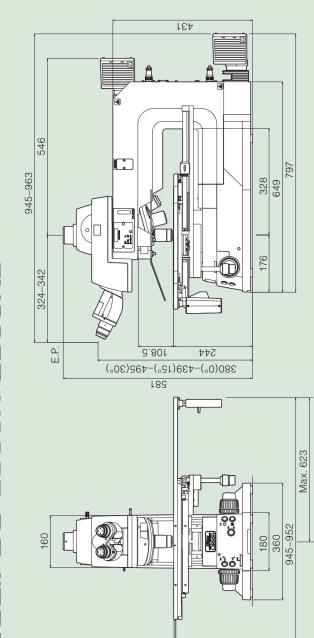


ECLIPSE L200N/L200ND

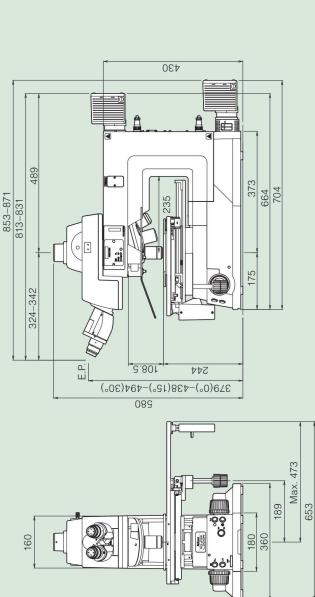


Dimensional diagram

ECLIPSE L300N/L300ND



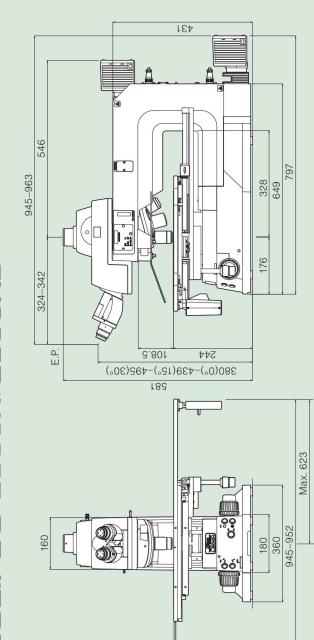
ECLIPSE L200N/L200ND



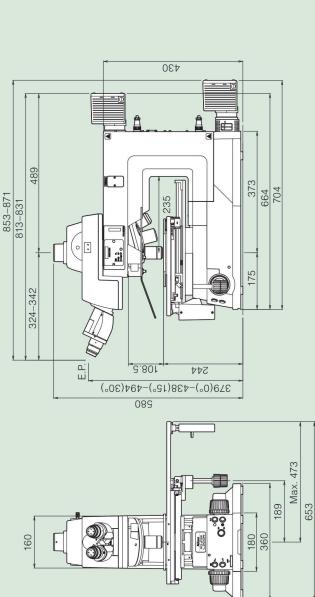
*1 Discoscopic illumination available only for L300ND and L200ND
*2 Epi-fluorescence observation available only for L300ND/L300NL200ND

Dimensional diagram

ECLIPSE L300N/L300ND



ECLIPSE L200N/L200ND



Specifications

	ECLIPSE L300N	ECLIPSE L200N	ECLIPSE L300ND	ECLIPSE L200ND			
Illumination type	Episcopic		Episcopic/Diascopic				
Main body	Power sources for motorized control built in Motorized control for nosepiece, Light intensity control, Aperture diaphragm control						
Nosepiece	Motorized universal sextuple nosepiece						
	Centering Function	Yes	—	Yes			
Focusing mechanism	EPI/DIA changeover	—	—	Yes			
	Cross travel	29 mm					
	Coarse	12.7 mm per rotation (torque adjustable, refocusing mechanism provided)					
Episcopic illuminator	Fine	0.1 mm per rotation (in 1 μm increments)					
	12V-50W halogen lamp light source built in, LV-LL LED Lamphouse Motorized aperture diaphragm (centerable), Fixed field diaphragm (with focus target) Pinhole slider (optional), Four ø25 mm filters (NCB11, ND16, ND4), Polarizer and Analyzer can be mounted Observation methods: Brightfield, Darkfield, Simple polarizing, DIC, Epi-fluorescence* (*L300N/L300ND/L200ND only)						
	Diascopic illuminator						
Interface	—		12V-50W halogen lamp light source built in, LV-LL LED Lamphouse Aperture diaphragm built in LWD condenser built in				
	USB x 1, RS232C (for Intensilight) x 1						
Eyepiece tubes	L2-TT2A Ultra-widefield erect-image tilting trinocular eyepiece tube (tilt angle: 0-30 °) FOV: 22/25; Beam split ratio 100:0/20:80 L2-TTA Ultra-widefield erect-image tilting trinocular eyepiece tube (tilt angle: 0-30 °) FOV: 22/25; Beam split ratio 100:0/0:100 LV-TI3 Trinocular eyepiece tube (erect image) FOV: 22/25; Beam split ratio 100:0/0:100						
	Eyepieces						
	Objective lenses						
Stages	14 x 12 stage	L2-S8A 8 x 8 stage	14 x 12 stage	L2-S8A 8 x 8 stage			
	Stroke	354 x 302 mm	205 x 205 mm	205 x 205 mm			
	Diascopic observation range	354 x 268 mm	150 x 150 mm	354 x 268 mm			
Coarse/Fine-movement changeover possible Fixed-position X-Y fine-movement controls							
Antistatic mechanism							
Power consumption							
Weight (approx.)	Body only	40 kg	30 kg	40 kg			
	With L2-S8A 8 x 8 stage and L2-TTA eyepiece tube	45 kg	45 kg	45 kg			

Specifications and equipment are subject to change without any notice or obligation on the part of the manufacturer. June 2023 ©2010-2023 NIKON CORPORATION

N.B. Export of the products* in this brochure is controlled under the Japanese Foreign Exchange and Foreign Trade Law. Appropriate export procedures shall be required in case of export from Japan.

*Products: Hardware and its technical information (including software)



TO ENSURE CORRECT USAGE, READ THE CORRESPONDING MANUALS CAREFULLY BEFORE USING THE EQUIPMENT.



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